#### **MEMBRANE HITEC**

Division of TITANIUM EQUIPMENT AND ANODE MANUFACTURING COMPANY LTD.





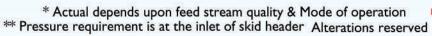
	OLINA HILINA	TION MEMBRANE DATA SH	
SPECIFICATION	UNIT	200MM DIA	200MM DIA
JF MEMBRANE DATA			
lodel No		RDMT-EM-35XVI-MBM-10/100KD	RDMT-EM-41XVI-MBM-10/100KE
ousing OD	mm	200	200
ousing Length	mm	1530 ± 1.0	1530 ± 1.0
ength with End Block	mm	1790 ± 5.0	1790 ± 5.0
lousing Material		UPVC	UPVC
nd Cap Material		PPGF	PPGF
eed / Permeate - Port size	inch	1½" Vitaulic	I ½" Vitaulic
ackwash In / Out - Port size	inch	1½" Vitaulic	1½" Vitaulic
mpty Weight with End Block	kg	29	29
JF MEMBRANE TYPE			
faterial	THE PERSON NAMED IN	Modified Polyether Sulphone	Modified Polyether Sulphone
уре		Multibore	Multibore
		IN to OUT	IN to OUT
Capillary per fibre	nos	7 (Multibore)	7 (Multibore)
ibre OD	mm	4	4
Capillary bore OD	mm	0.8	0.8
1WCO	KD	10/100	10/100
ctive Surface Area	m <sup>2</sup>	35	41
JF OPERATIONAL DATA			
Operating Temperature	°C	15 - 45	15 - 45
lode of operation		Dead end / Cross Flow	Dead end / Cross Flow
Operating Flux *	lmh	30 - 120	30 - 120
eed pressure** max	bar	2.0	2.0
ransmembrane pressure max	bar	1.0	1.0
H range during operation	Jai	4-10	4-10
H during chemical cleaning		2 - 14	2-14
JF MEMBRANE REGENERAT	TION CYCLES	2.5.17	25.17
ackwash pressure** min/max	bar	1.5 - 2.5	1.5 - 2.5
ackwash Flux *	lmh	170 - 240	170 - 240
ackwash frequency	min	30 - 60	30 - 60
ackwash duration		30 - 60	30 - 60
ackwash duration orward flush duration	Sec	15 - 45	30 - 60 15 - 45
orward flush flux	sec	as feed flux	as feed flux
DISINFECTION & CHEMI	7539	Mary and consistency and an advantage of the constraint of the con	as leed flux
	CAL CLEANIN		
DISINFECTION CHEMICALS		25, 222	25 222
odium hypo chlorite (NaOCI)	ppm	25 - 200	25 - 200
LEANING CHEMICALS	1575	Hypo, Caustic soda, HCI	Hypo, Caustic soda, HCl
CI	pН	3 - 4	3 - 4
aOH	pH min	12 - 13	12 - 13
hemical cleaning duration	min	30 - 60 Weekly once or Depends on fee	30 - 60
hemical cleaning frequency		Weekly once or Depends on fee	eu quality & pathogens load
ILTRATE QUALITY		DE DENZO.	ggranner.
\$\$	ppm	< 1.0	< 1.0
urbidity *	NTU	< 0.5	< 0.5
icro-organism, Bacteria, suedomonas diminuta, E.coli, etc*	log reduction	> 4	> 4
DI*		< 3	< 3

# **MEMBRANE HITEC**



		TRATION MEMBRANE DATAS	SHEET
SPECIFICATION	UNIT	225 MM DIA	225 MM DIA
F MEMBRANE DATA			
odel No		RDMT-EM-50 XVI-SBM-100KD	RDMT-EM-65 XVI-SBM-100KD
ousing OD	mm	225	225
ousing Length	mm	1500 ± 2.0	1830 ± 2.0
ength with End Block	mm	1705 ± 5.0	2035 ± 5.0
ousing Material		UPVC	UPVC
nd Cap Material		PPGF	PPGF
eed / Permeate - Port size	inch	2" Vitaulic	2" Vitaulic
ckwash In / Out - Port size	inch	2" Vitaulic	2" Vitaulic
npty Weight with End Block	kg	32	40
F MEMBRANE TYPE		-	
terial		Modified Polyether Sulphone	Modified Polyether Sulphone
pe		Singlebore	Singlebore
		IN to OUT	IN to OUT
apillary per fibre	nos		The state of the s
bre OD	mm	1.5	1.5
apillary bore ID	mm	0.9	0.9
wco	KD	100	100
ctive Surface Area	m <sup>2</sup>	50	65
F OPERATIONAL DATA	19 (81		03
perating Temperature	°C	15 - 45	15 - 45
ode of operation	9	Dead end / Cross Flow	Dead end / Cross Flow
perating Flux *	lmh	30 - 120	30 - I20
ed pressure** max	bar	2.0	2.0
ransmembrane pressure max	bar	1.0	1.0
range during operation	bai	4-10	4-10
during chemical cleaning		2 - 14	2-14
	PATION CYC	177 303	2- 14
F MEMBRANE REGENE	- N		11.25
ckwash pressure** min/max	bar	1.5 - 2.5	1.5 - 2.5
ckwash Flux *	lmh	170 - 240	170 - 240
ckwash frequency	min	30 - 60	30 - 60
ackwash duration	sec	30 - 60	30 - 60
rward flush duration	sec	15 - 45	15 - 45
orward flush flux	Imh	as feed flux	as feed flux
F DISINFECTION & CH	EMICAL CLEA	NING	
SINFECTION CHEMICALS			
odium hypo chlorite (NaOCI)	ppm	25 - 200	25 - 200
LEANING CHEMICALS	-11	Hypo, Caustic soda, HCI	Hypo, Caustic soda, HCI 3 - 4
CI SOU	pН	3 - 4 12 - 13	3 - <del>4</del> 12 - 13
aOH nemical cleaning duration	pH min	12 - 13 30 - 60	12 - 13 30 - 60
nemical cleaning duration	STORE	Weekly once or Depends on fe	
amenta (1966) a tractica de esta a fasta de la composición del composición de la composición de la composición del composición de la composición de la composición del composición de la composición de la composición de la composición de la composición del com		vveekly once or Depends on to	eed quality & patriogens load
ILTRATE QUALITY			
SS *	ppm	< 1.0	< 1.0
urbidity *	NTU	< 0.5	< 0.5
icro-organism, Bacteria, uedomonas diminuta, E.coli, etc*	} log reduction	> 4	> 4
DI*		< 3	< 3







**TEAM** 

	ULTRA FII	LTRATION MEMBRANE DATA	1 STILL I
SPECIFICATION	UNIT	280MM DIA	400MM DIA
JF MEMBRANE DATA			
1odel No		RDMT-EM-81XVI-SBM-100KD	RDMT-EM-100XVI-MBM-10/100 KD
lousing OD	mm	280	400
lousing Length	mm	1830 ± 1.0	1530 ± 1.0
ength with End Block	mm	2127 ± 5.0	1880 ± 5.0
lousing Material		UPVC	UPVC
nd Cap Material		PPGF/SS304	PPGF/SS304
eed / Permeate - Port size	inch	2" Vitaulic	2½" Vitaulic
ackwash In / Out - Port size	inch	2" Vitaulic	2½" Vitaulic
mpty Weight with End Block	kg	65	99
JF MEMBRANE TYPE			
aterial		Modified Polyether Sulphone	Modified Polyether Sulphone
уре		Singlebore	Multibore
Contract of the Contract of th		IN to OUT	IN to OUT
apillary per fibre	nos	T	7 (Multibore)
ibre OD	mm	1.5	4
Capillary bore ID	mm	0.9	0.8
iwco	KD	100	10/100
active Surface Area	m <sup>2</sup>	- 81	100
JF OPERATIONAL DATA			
perating Temperature	°C	15 - 45	15 - 45
lode of operation		Dead end / Cross Flow	Dead end / Cross Flow
perating Flux *	lmh	30 - 120	30 - 120
eed pressure** max	bar	2.0	2.0
ransmembrane pressure max	bar	1.0	1.0
H range during operation		4 - 10	4 - 10
H during chemical cleaning		2 - 14	2 - 14
JF MEMBRANE REGENE	RATION CYC	180 190	
ackwash pressure** min/max	bar	1.5 - 2.5	1.5 - 2.5
ackwash Flux *	lmh	170 - 240	170 - 240
ackwash frequency	min	30 - 60	30 - 60
ackwash duration	sec	30 - 60	30 - 60
orward flush duration	sec	15 - 45	15 - 45
orward flush flux	lmh	as feed flux	as feed flux
JF DISINFECTION & CH	20000000		as locd flux
ISINFECTION CHEMICALS			
odium hypo chlorite (NaOCl)	ppm	25 - 200	25 - 200
LEANING CHEMICALS	PP"	Hypo, Caustic soda, HCl	Hypo, Caustic soda, HCI
	-11	3 - 4	3 - 4
ICI IaOH	pН	3 - <del>4</del> 12 - 13	3 - <del>4</del> 12 - 13
hemical cleaning duration	pH min	30 - 60	12 - 13 30 - 60
hemical cleaning frequency	umi		n feed quality & pathogens load
The second secon		Treekly office of Depertus of	rices quality & patriogens load
ILTRATE QUALITY	7.05522	210	>10
SS *	ppm	< 1.0	< 1.0
urbidity *	NTU	< 0.5	< 0.5
licro-organism, Bacteria, suedomonas diminuta, E.coli, etc*	log reduction	> 4	> 4
DI*		< 3	< 3

# **MEMBRANE HITEC**

### **Ultra Filtration Technology**

Membrane Hitec (MHT), member Dr. Rao Holdings Pte Ltd., Singapore, is the pioneering manufacturer of Capillary Ultrafiltration Membranes in India. The technology was developed by Membrane Research Technology Singapore and transferred to its Indian Regional Manufacturing Company. The Intellectual Property Rights have been registered in Singapore.

# **UF Applications**

Boiler Feed Water - Colloidal Silica Removal

Pre - Treatment to R/O - Reduction of SDI

Drinking Water - Removal of Pathogens

Pre treatment to Desalination - SDI Reduction

Cooling Tower - Removal of Suspended Solids / Microbes

Treated Sewage - TSS / Turbidity / SDI Reduction

Brine Clarification - Chlor - Alkali - TSS / Turbidity Reduction

Process Effluent Recycling - TSS / Turbidity / SDI Reduction

# Advantages - MHT UF Membranes

Low Operating Pressure (0.5 to 0.8 Bar)

High Performance Anti Fouling Characteristics

Operating in Dead end / Cross Flow

MWCO Range 10 KD to 100 KD

Same UF Feed Pump used for forward Flush A & B

Reduces Foot print with 100 m<sup>2</sup> unique membrane design

Elimination of pre - coat filters

Lower Power Consumption

620



Raw Water Treatment Plant



Post DM



**Effluent Treatment Plant** 



Post DM



Cogen Power Plant



Post DM



**Effluent Treatment Plant** 



Cooling Tower Blow-Down



Division of TITANIUM EQUIPMENT AND ANODE MANUFACTURING COMPANY LTD.





